



Ultrafast Laser Physics

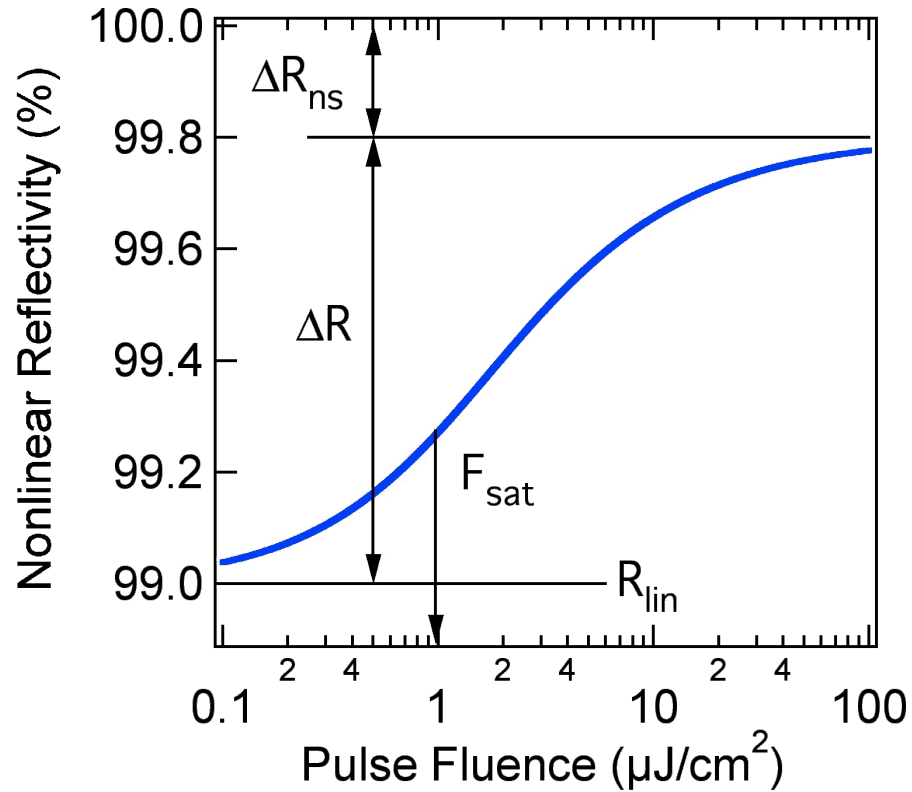
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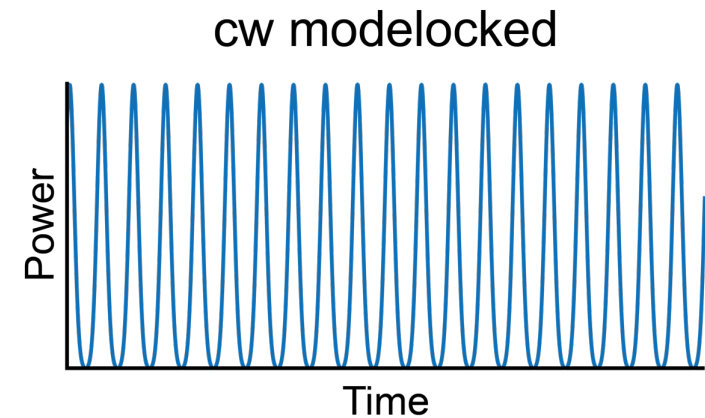
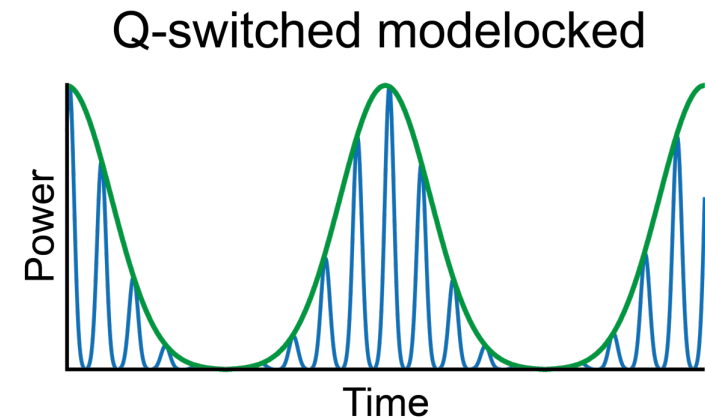
Chapter 8: Passive modelocking: Q-switching instabilities

nonlinear parameters

$$F_{\text{sat}}, \Delta R, \Delta R_{\text{ns}}$$



to overcome the stability condition for Q-switched mode locking (QML) threshold



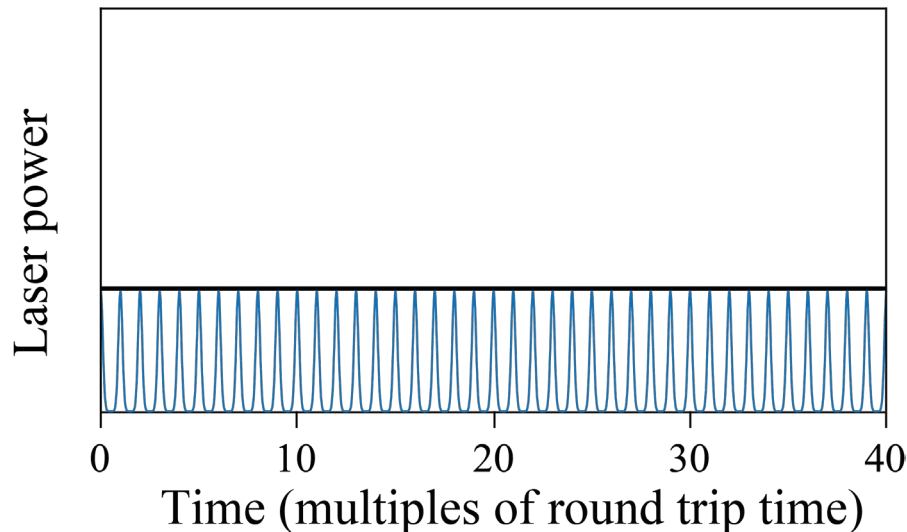
Q-switched modelocking is avoided if...

C. Hönninger, R. Paschotta, F. Morier-Genoud, M. Moser, and U. Keller,
JOSA B **16**, 46 (1999)

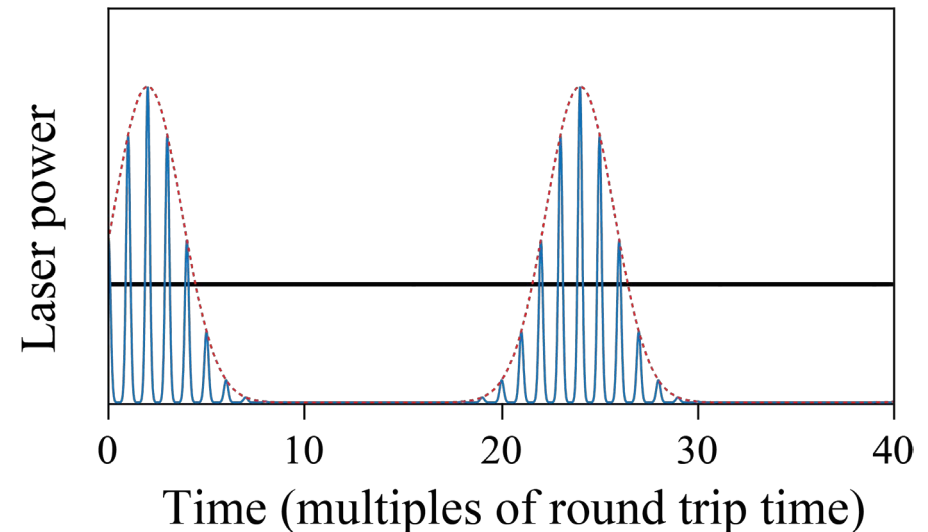
$$E_p^2 > E_{\text{sat,L}} E_{\text{sat,A}} \Delta R$$

$$= \left(\frac{P_{\text{intra}}}{f_{\text{rep}}} \right)^2 \propto \frac{A_{\text{eff,L}}}{\sigma_{\text{em,L}}} = A_{\text{eff,A}} F_{\text{sat,A}} \Delta R$$

cw modelocking



Q-switched modelocking



Saturation fluence and modulation depth

C. Hönninger, R. Paschotta, F. Morier-Genoud, M. Moser, and U. Keller, *JOSA B* **16**, 46 (1999)

SESAM

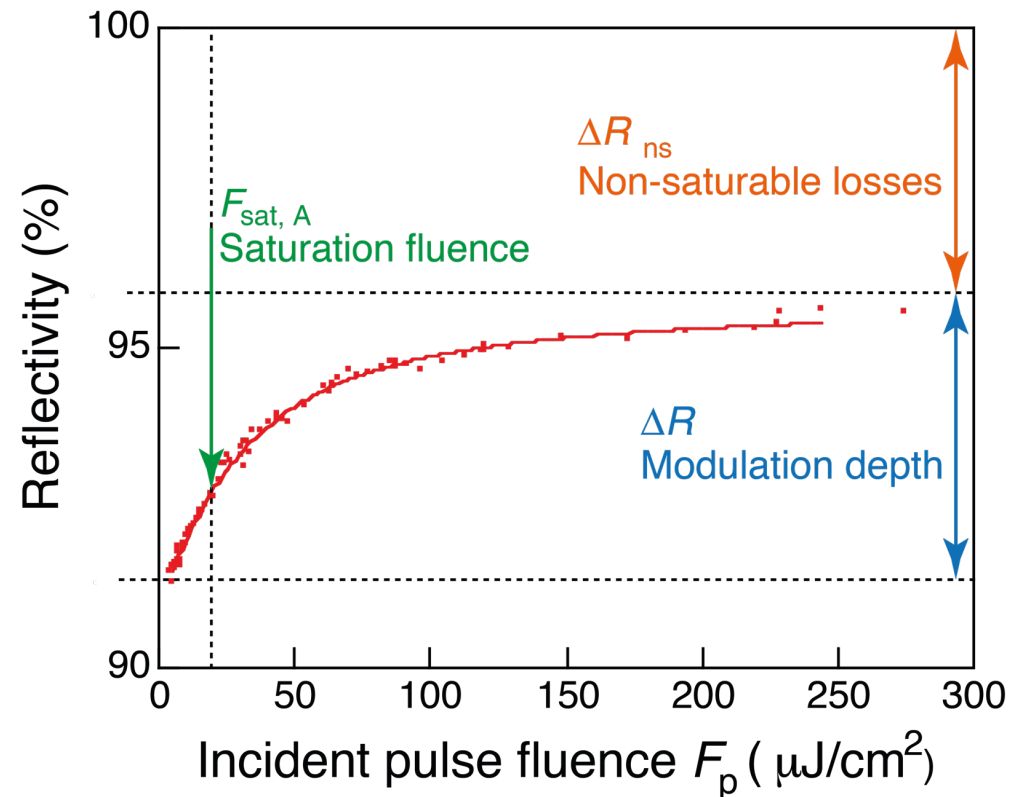
$$E_p^2 > E_{\text{sat,L}} E_{\text{sat,A}} \Delta R$$

Semiconductor saturable absorber mirror

$$A_{\text{eff,A}} F_{\text{sat,A}} \Delta R$$

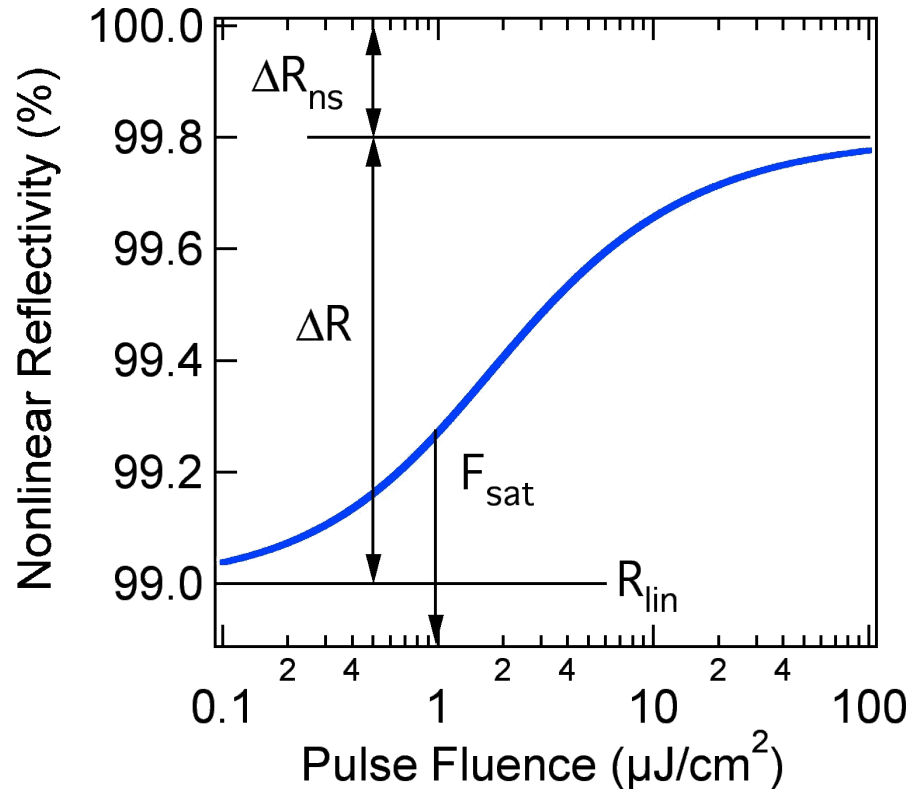
$$F_{\text{sat,A}} \propto \frac{1}{\sigma_A}$$

Absorber	σ_A [cm ²]
ion-doped solid-state	$10^{-19} - 10^{-22}$
dye	10^{-16}
semiconductor	10^{-14}



nonlinear parameters

$$F_{\text{sat}}, \Delta R, \Delta R_{\text{ns}}$$



to overcome the stability condition for Q-switched mode locking (QML) threshold

$$F_p^2 > F_{\text{sat}} \cdot \Delta R \cdot F_{\text{sat,L}} \cdot \frac{A_{\text{eff,L}}}{A_{\text{eff,A}}}$$

F_p : intracavity fluence

F_{sat} : saturation fluence of the absorber

ΔR : modulation depth

$F_{\text{sat,L}}$: saturation fluence of the gain

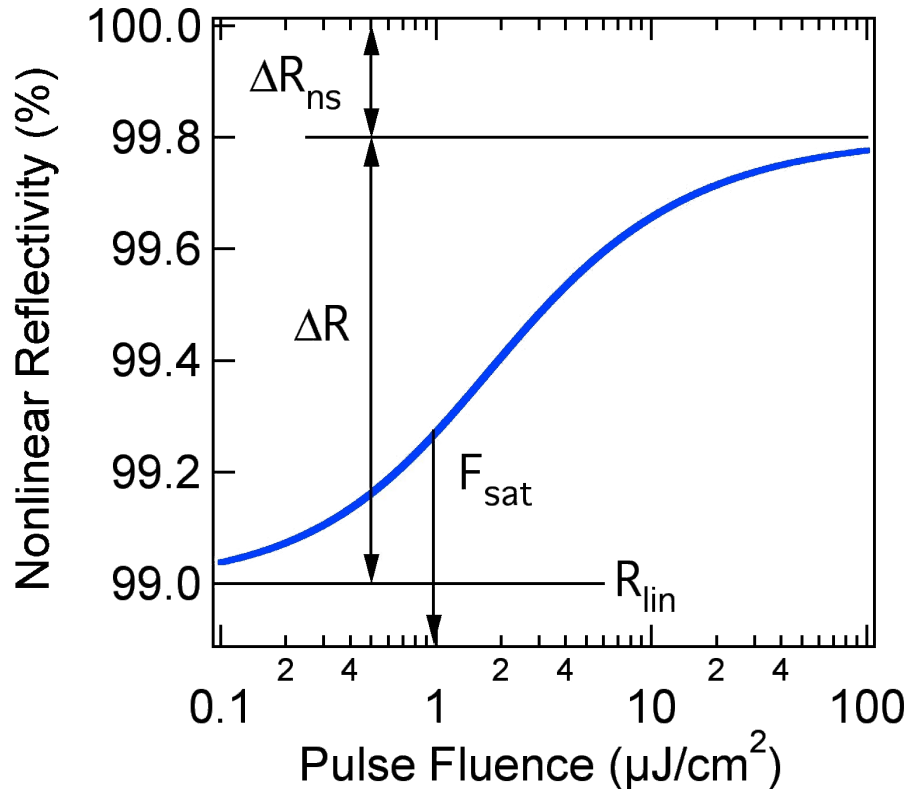
A : area in gain medium and on absorber

C. Hönninger, R. Paschotta, F. Morier-Genoud, M. Moser, U. Keller, JOSA B **16**, 46-56 (1999)

Keep ΔR and F_{sat} small to avoid Q-switching instabilities

nonlinear parameters

$$F_{\text{sat}}, \Delta R, \Delta R_{\text{ns}}$$



to overcome the stability condition for Q-switched mode locking (QML) threshold

$$F_p^2 > F_{\text{sat}} \cdot \Delta R \cdot F_{\text{sat,L}} \cdot \frac{A_{\text{eff,L}}}{A_{\text{eff,A}}}$$

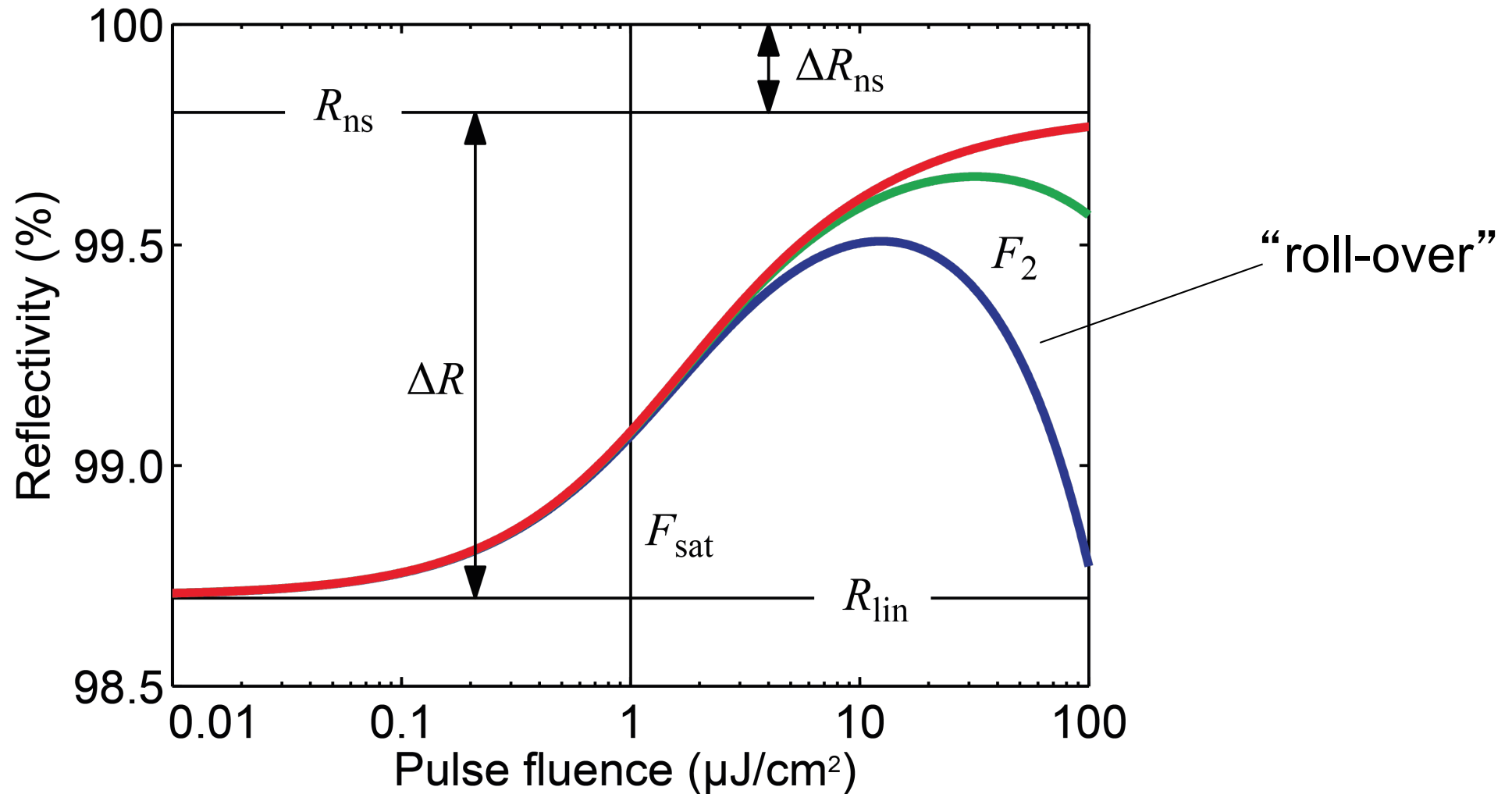
Issues for high pulse repetition rates:

$E_{p, \text{GHz}}$ 10^{-3} smaller than $E_{p, \text{MHz}}$

- $F_{\text{sat}} \sim$ few tens of $\mu\text{J}/\text{cm}^2$
- $\Delta R < 1\%$ is required

Keep ΔR and F_{sat} small to avoid Q-switching instabilities

SESAM response with roll-over (inverse sat. absorption)



T. R. Schibli et al., Appl. Phys. B 70, S41-S49 (2000).

R. Grange et al., App. Phys. B 80, 151-158 (2005).

Inverse saturable absorption improves QML threshold

Simple stability condition, $F_2 \rightarrow \infty$

$$F_p^2 > F_{\text{sat}} \cdot \Delta R \cdot F_{\text{sat,L}} \cdot \frac{A_{\text{eff,L}}}{A_{\text{eff,A}}}$$

F_p = intracavity fluence

$F_{\text{sat,L}}$ = gain saturation fluence

F_{sat} = absorber saturation fluence

C. Hönninger, et al., JOSA B **16**, 46-56 (1999)

Modified stability condition

$$F_p^2 > \frac{F_{\text{sat}} \Delta R}{\frac{1}{A_L F_{\text{sat,L}}} + \frac{1}{A_A F_2}}$$

A_A = beam size area on the absorber

T. R. Schibli, et al., Appl. Phys. B **70**, S41-S49 (2000)

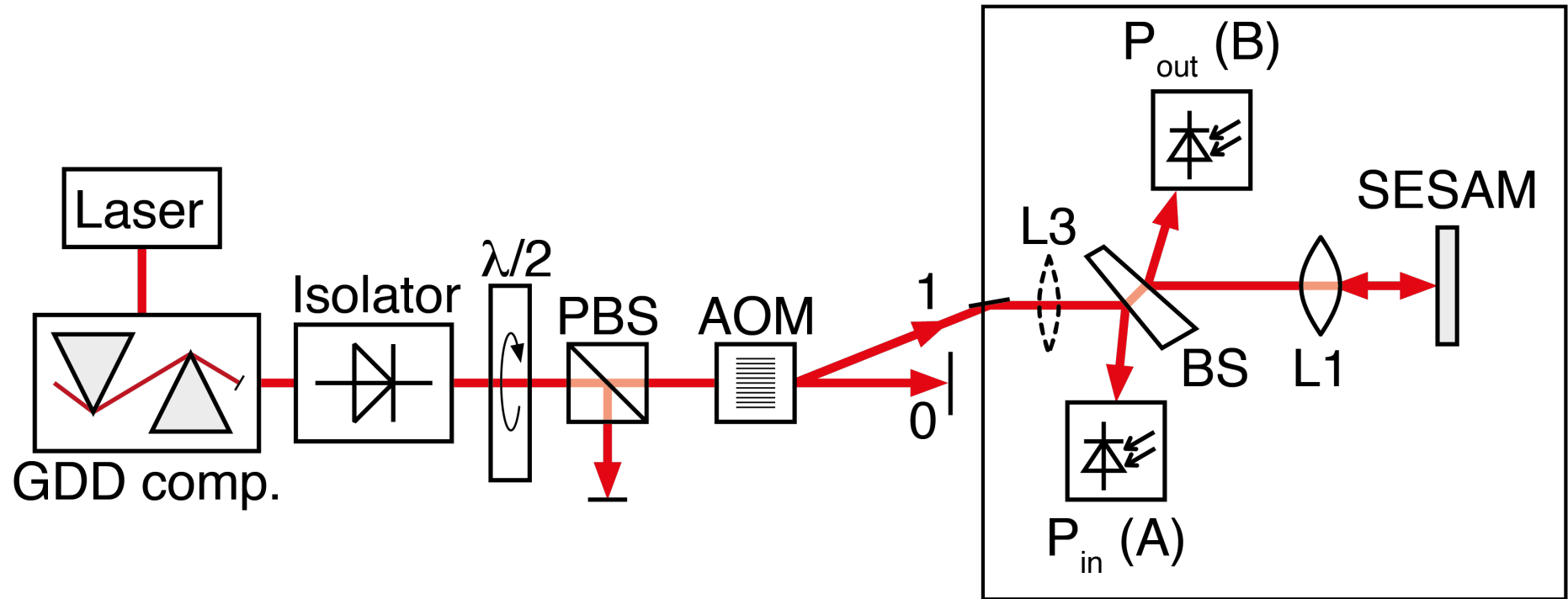
R. Grange, et al., Appl. Phys. B **80**, 151-158 (2005)

- Reduced QML threshold
- Less need of minimization of the mode size in the gain medium



- Measurement of SESAM parameters

Haiml et al., *Appl. Phys. B* **79**, 331-339 (2004)

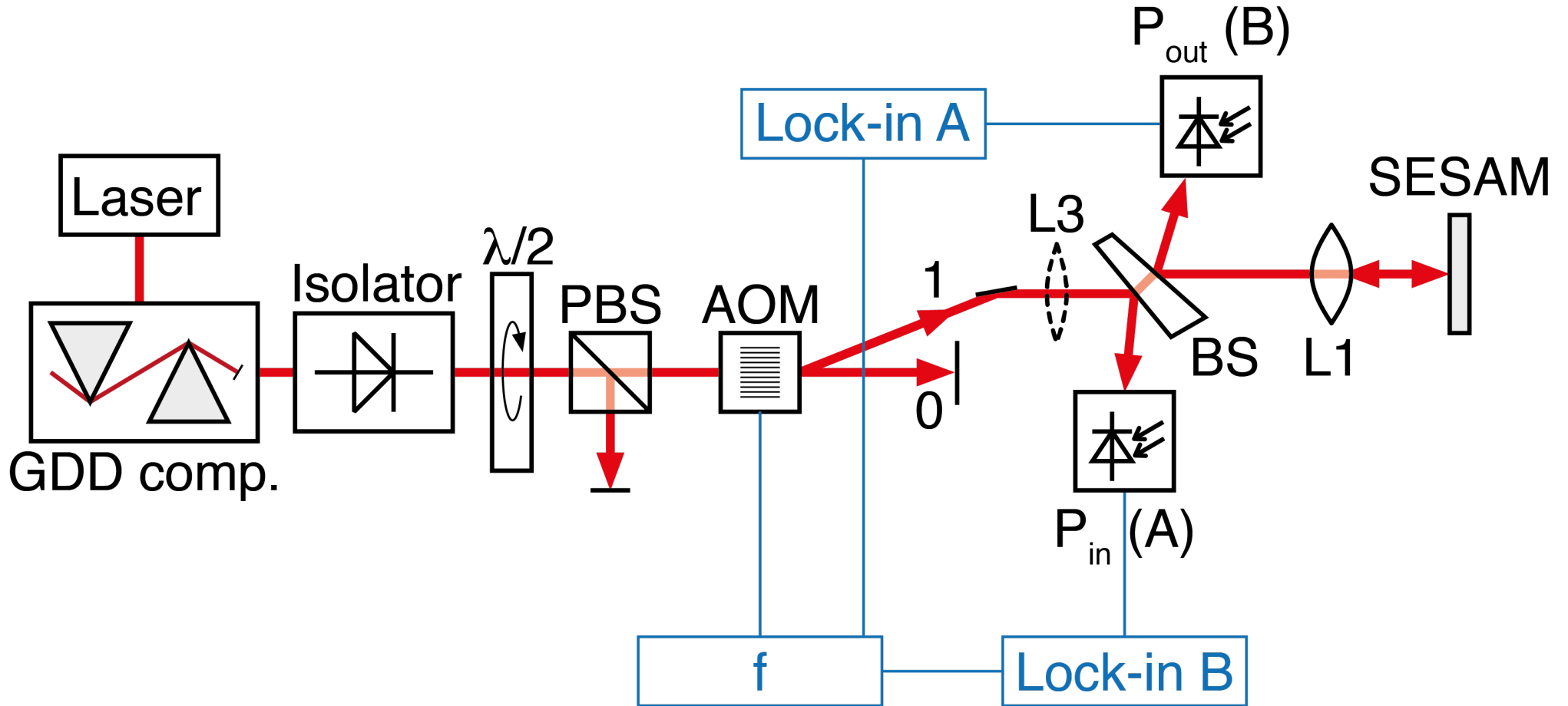


Photodiode A: $\propto P_{in}$

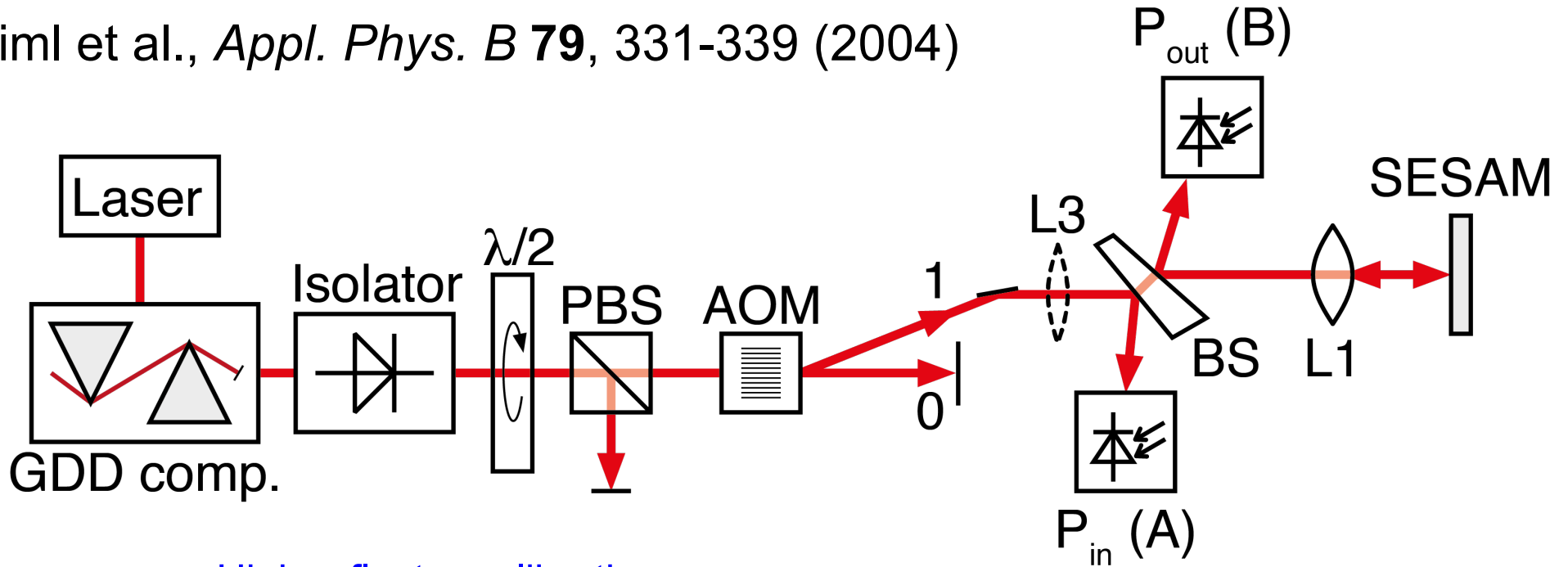
Photodiode B: $\propto R \cdot P_{in}$

Reflectivity of the SESAM: $R = \frac{B}{A}$

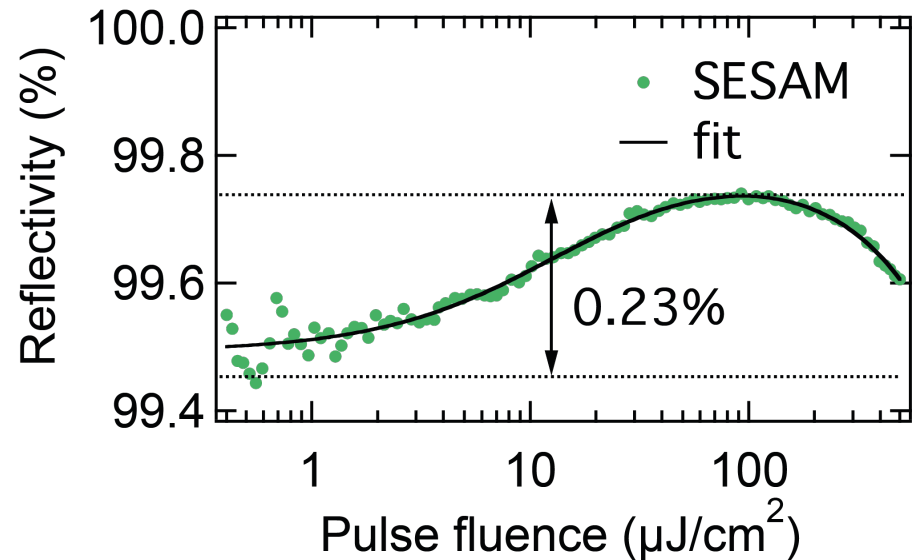
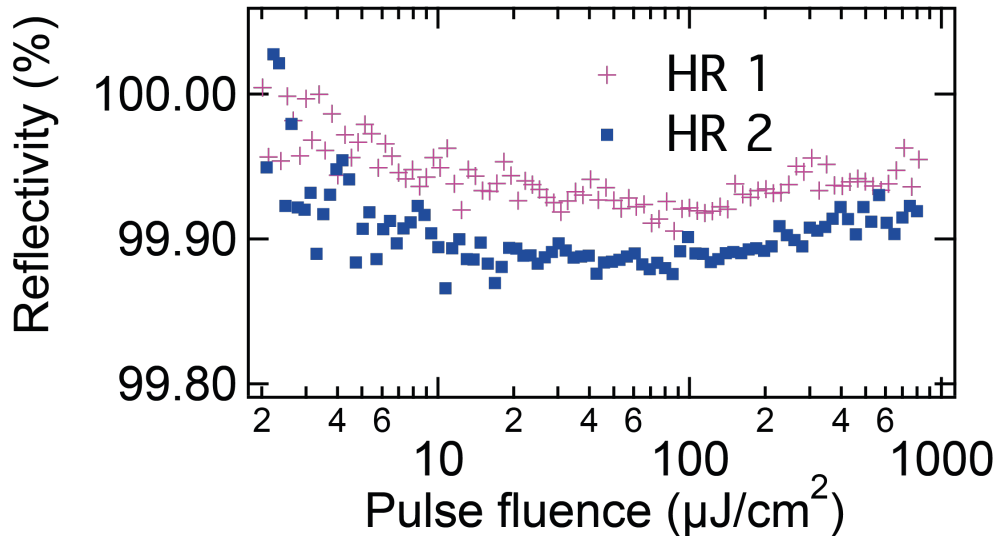
Haiml et al., *Appl. Phys. B* **79**, 331-339 (2004)



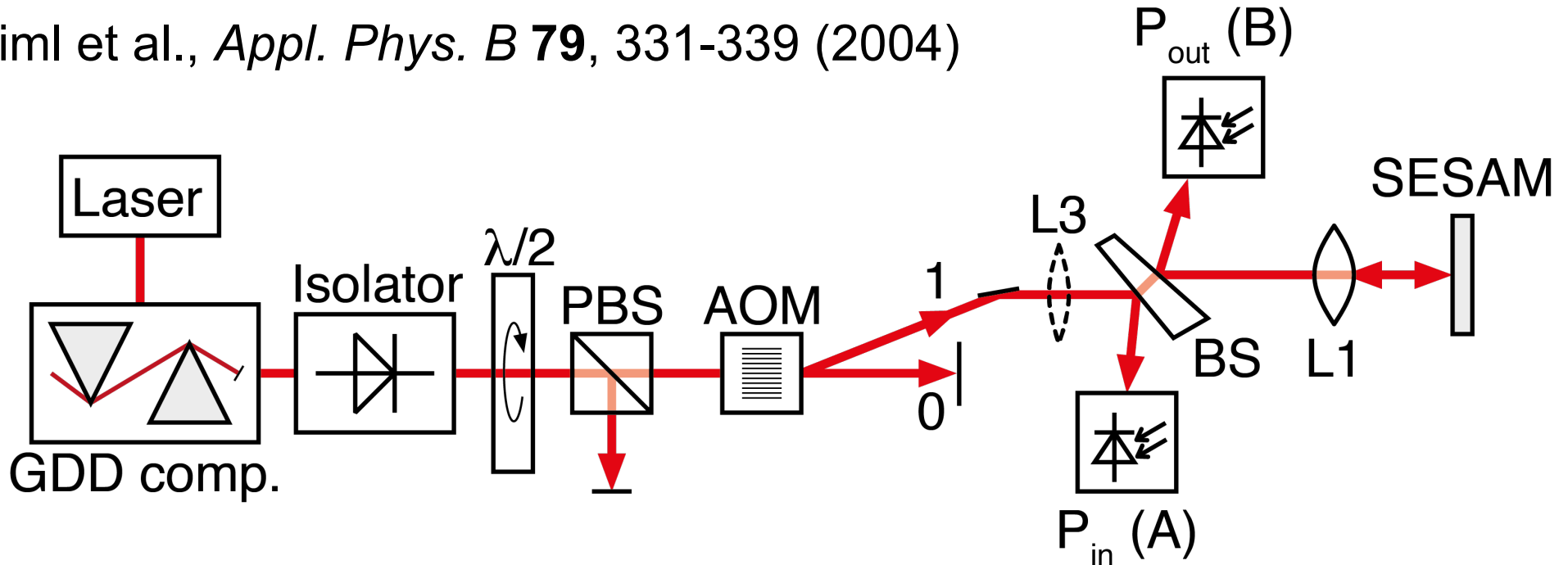
Haiml et al., *Appl. Phys. B* **79**, 331-339 (2004)



High reflector calibration



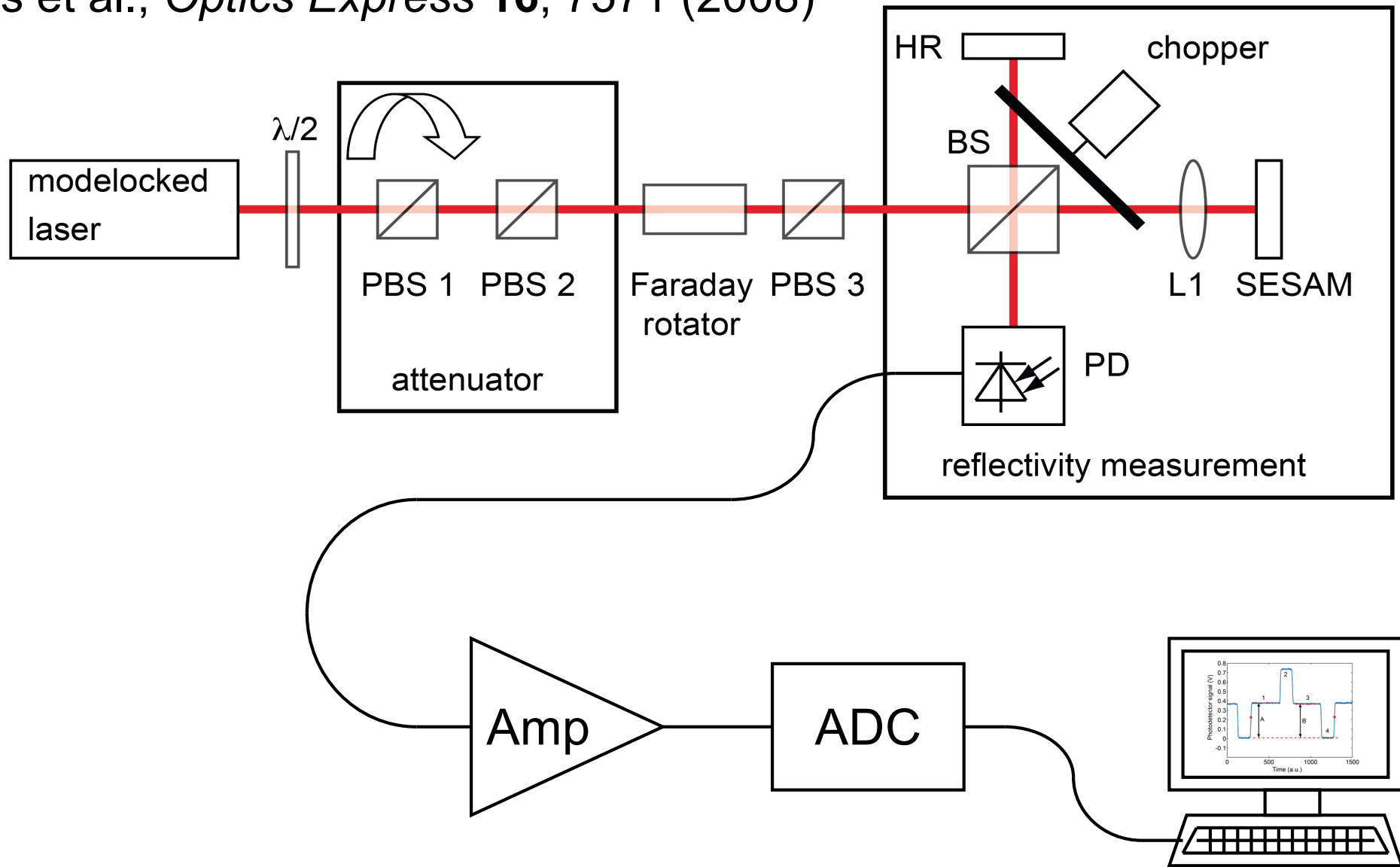
Haiml et al., *Appl. Phys. B* **79**, 331-339 (2004)



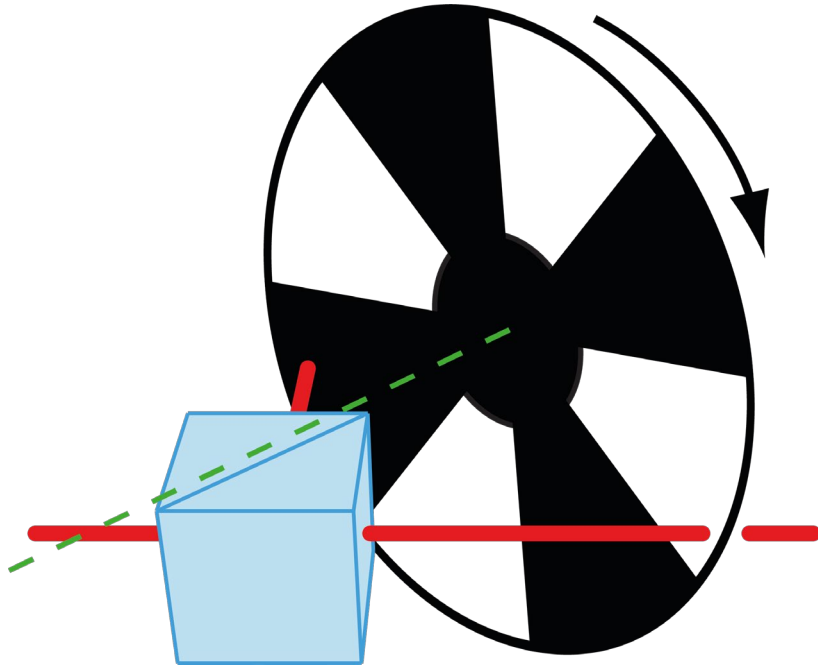
- Detectors must be able to measure voltages over at least four orders of magnitude with an accuracy of better than 0.1%
- Lock-in detection with two separate lock-in amplifiers (AOM needed for modulation of the incident beam)
- Required performance is close to the linearity limit of the lock-in amplifiers
- **Complicated and expensive**

New measurement system

Maas et al., *Optics Express* **16**, 7571 (2008)

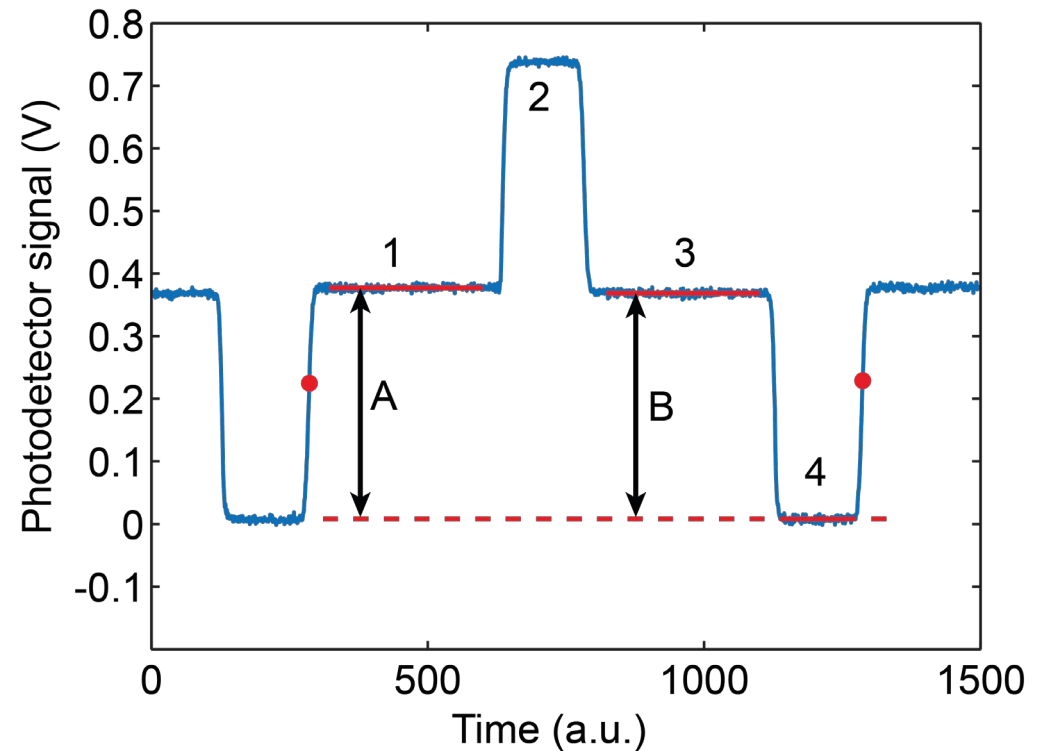


Maas et al., *Optics Express* **16**, 7571 (2008)

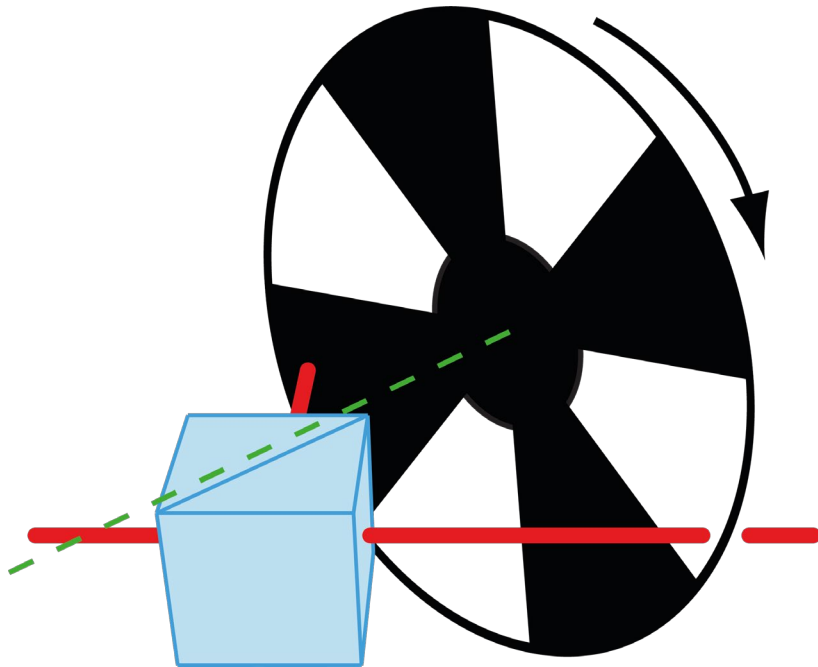


4 “states”:

1. Reference mirror signal
2. Both signals (ignore this)
3. SESAM signal
4. Both arms blocked → background signal



Maas et al., *Optics Express* **16**, 7571 (2008)

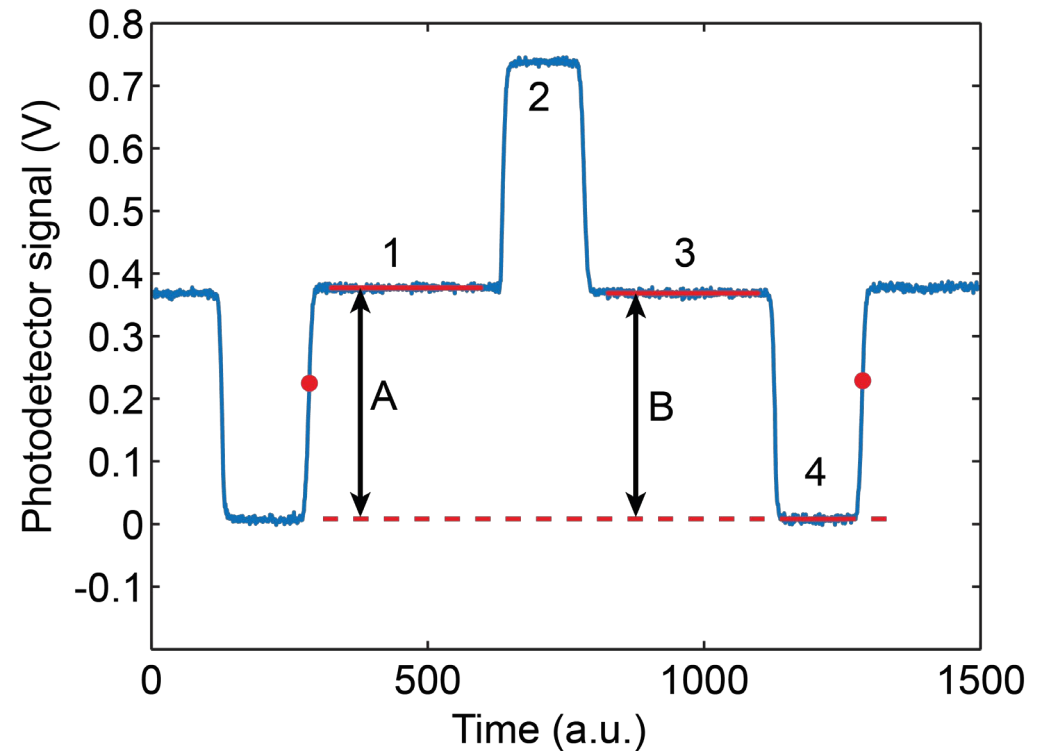


Nonlinear reflectivity: $R = \frac{B}{A}$

Incident fluence:

Calculated from voltage A and pre-amplifier gain

5% accuracy is good enough \Rightarrow 5% inaccuracy of F_{sat}

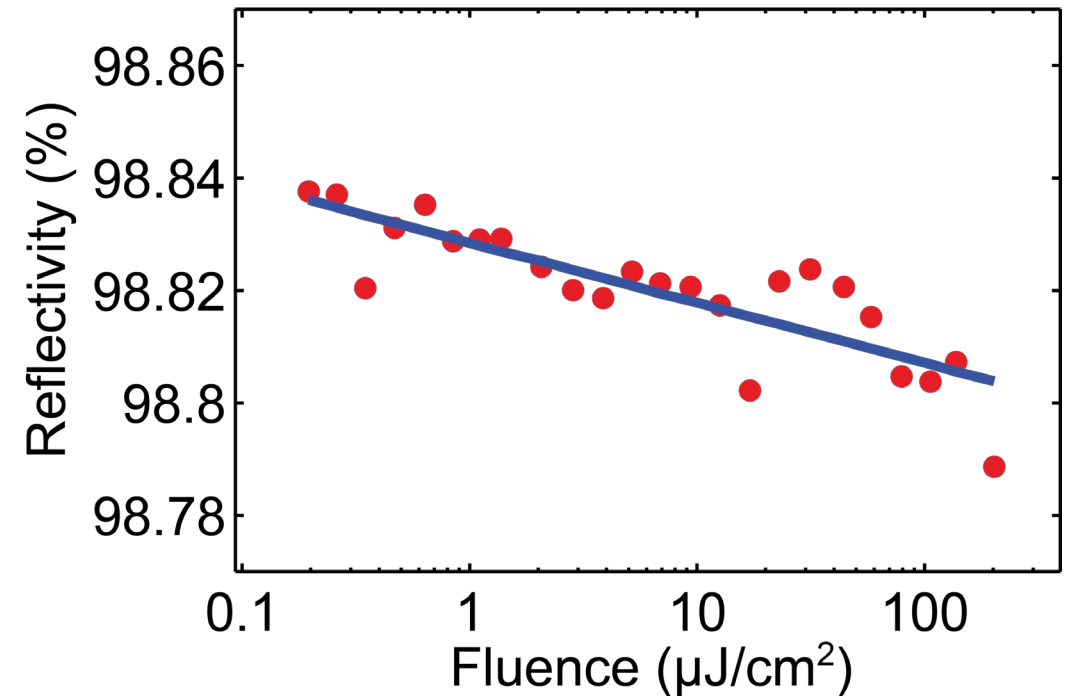


Maas et al., *Optics Express* **16**, 7571 (2008)

Calibration is done with a HR
instead of the SESAM:

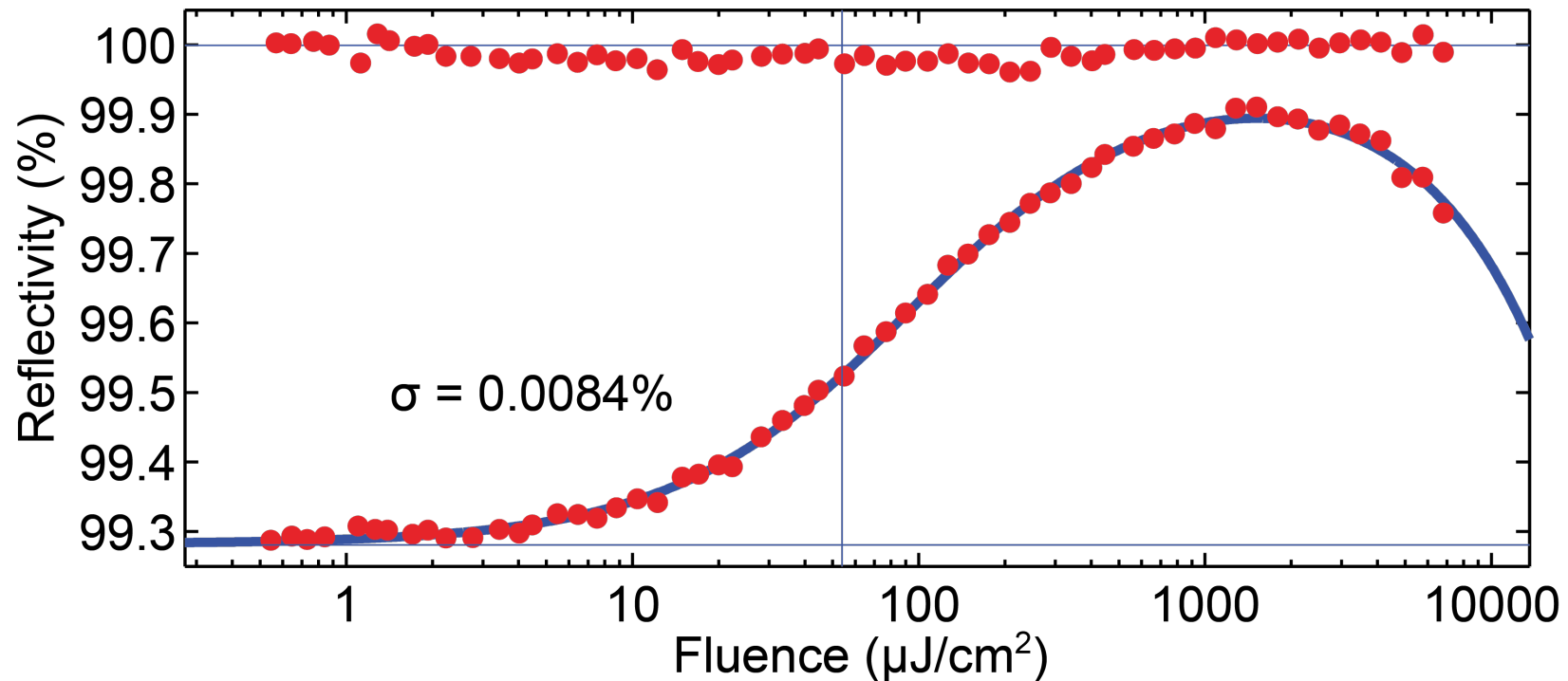
Reflectivity should be 100%
and flat, but

- extra lens in SESAM arm
- systematic errors



➔ Introduction of a calibration function $C(F)$

The corrected nonlinear reflectivity is then:
$$R = C(F) \cdot \frac{B}{A}$$



Laser Source: modelocked Yb:Lu₂O₃ thin disk laser
570 fs pulses, 65 MHz ➔ induced absorption

Calibration function C(F): second order polynomial of log(F)

HR with correction: flatness of 0.055%

SESAM parameters: $F_{\text{sat}} = 54 \mu\text{J}/\text{cm}^2$, $\Delta R = 0.72\%$, $F_2 = 3.3 \text{ J}/\text{cm}^2$